

Information Notice

Tender: ALD



Nr.	Document	Section/Article	Question	Answer
1	Annex F Requirements	Req. 5.1	We will offer a true remote CCP plasma source; is this acceptable?	In view of the envisioned use of the equipment, a conductively coupled plasma source (remote or otherwise) does not suit our needs and will not be accepted.
2	Annex F Requirements	Req. 2.2	We will ship process for AlN using NH3 instead of N2/H2, is this ok?	No, this is not permitted. For maximum flexibility, we aim to run experiments where the N2/H2 ratio is a variable.
3	Annex 3 Draft Contract	Draft contract, point 3.3	In requirement 2 you ask for deposition of Al ₂ O ₃ , AlN, Pt. In your draft of the contract there is a bigger list in point 3.3. Our tool can deposit the coatings. But is it necessary to ship and show them for final acceptance?	No, it is not required to ship and show the materials in point 3.3 of the draft contract for final acceptance. For the list in the draft contract 3.3, we ask for documentation on the recipes, to provide an easy starting point for us and our users if those processes would be carried out at